

APPLICANT'S ART CITATION (Use several sheets if necessary)	Application 10/613,574	OGFS File No. P/2850-79
	Applicant Takeshi OOTSUKA	
	Filing Date July 9, 2003	Group Art Unit

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
YC	US-2003/0089687	05-2003	Maki			
YC	US-2002/0006678	01-2002	Inazumachi, et al.			
YC	US-5,688,331	11-1997	Aruga, et al.			
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	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation	
						Yes	No
YC	2001-287982	10-2001	Japan				X
YC	2003-152064	05-2003	Japan				X
YC	7-153706	06-1995	Japan				X
YC	JP-4-3001136	10-1992	Japan				X
YC	JP-6-151044	05-1994	Japan				X
YC	JP-6-151332	05-1994	Japan				X
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YC	2003-124296	04-2002	Japan				X
YC	JP-2001-085505	03-2001	Japan				X
YC	JP-2001-308165	02-2001	Japan				X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

YC	English translation of Abstract for Japenese Patent Application No. JP-4-3001136
YC	English translation of Abstract for Japenese Patent Application No. JP-6-151044
YC	English translation of Abstract for Japenese Patent Application No. JP-6-151332
YC	English translation of Abstract for Japenese Patent Application No. JP-10-189696
YC	English translation of Abstract for Japenese Patent Application No. 2003-124296
YC	English translation of Abstract for Japenese Patent Application No. JP-2001-085505

Examiner

Date Considered

2/11/2004

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